Electronic Supplementary Material (ESI) for Polymer Chemistry.

Supplementary Information

Synthesis, Thin-Film Self-Assembly, and Pyrolysis of Ruthenium-containing Polyferrocenylsilane Block Copolymers

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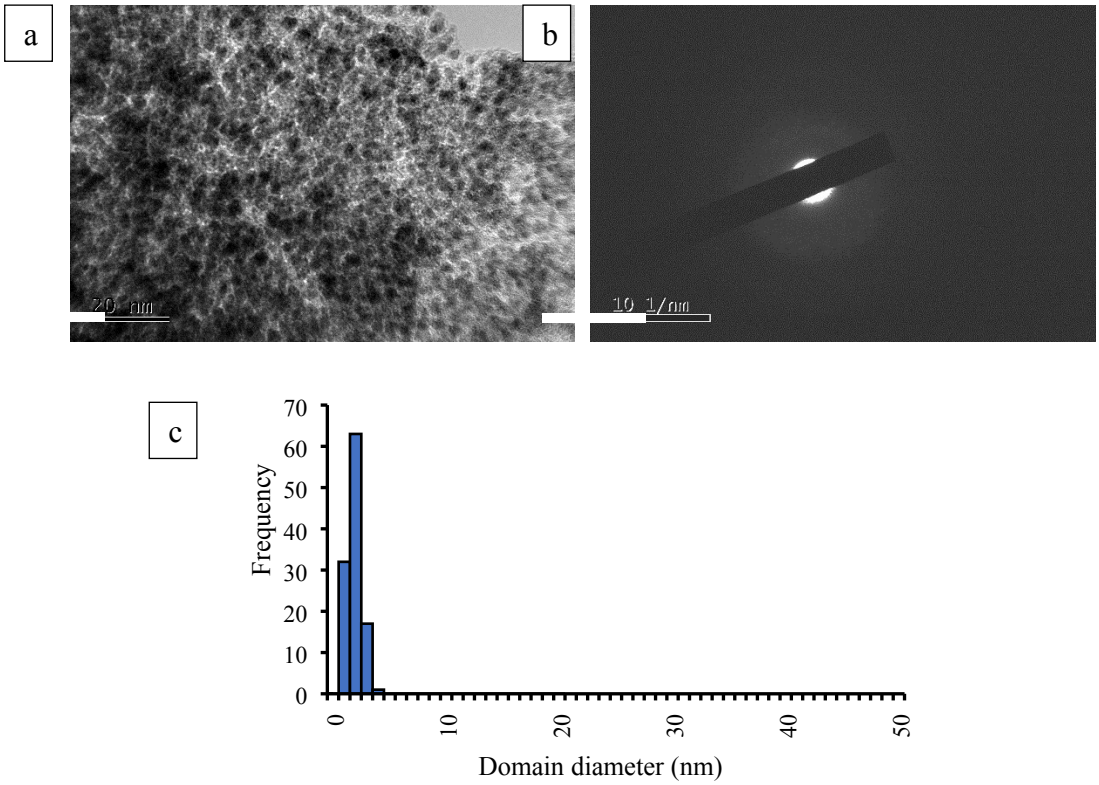

Figure S1: Characterisation of sample **$9B_{500\text{-}2h}$** (a) High Resolution TEM image; (b) SAED pattern and (c) diameter distribution of NPs in (a).

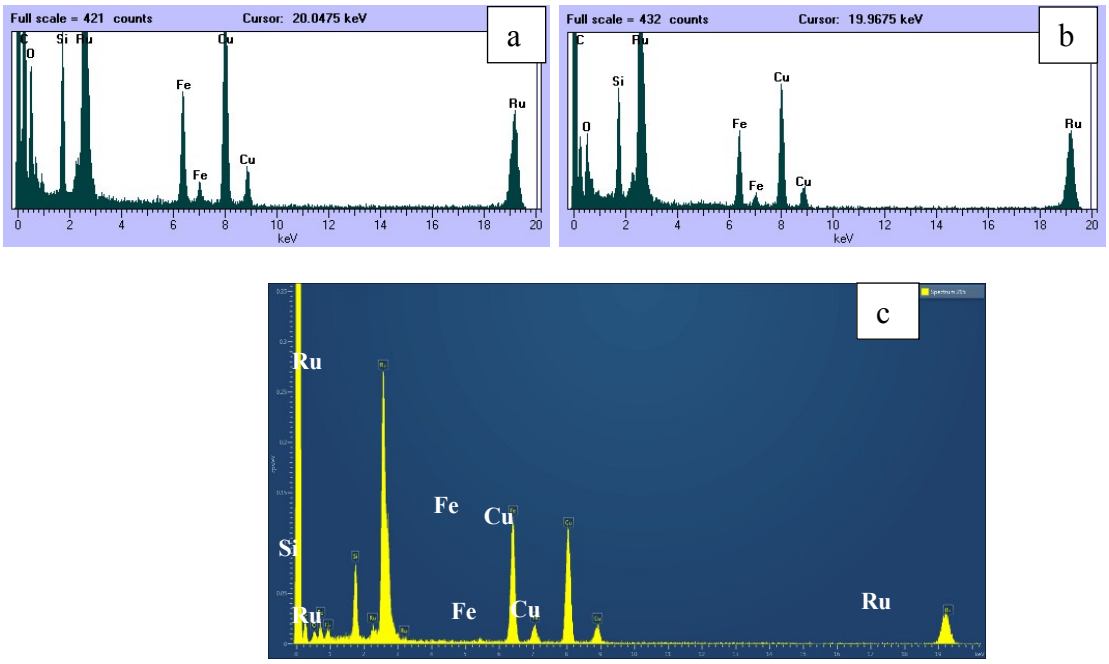

Figure S2: EDX analysis plots for samples: (a) **9A$_{500\text{-}2h}$**, (b) **9A$_{800\text{-}2h}$** and (c) **9B$_{800\text{-}2h}$** on a Cu TEM grid.

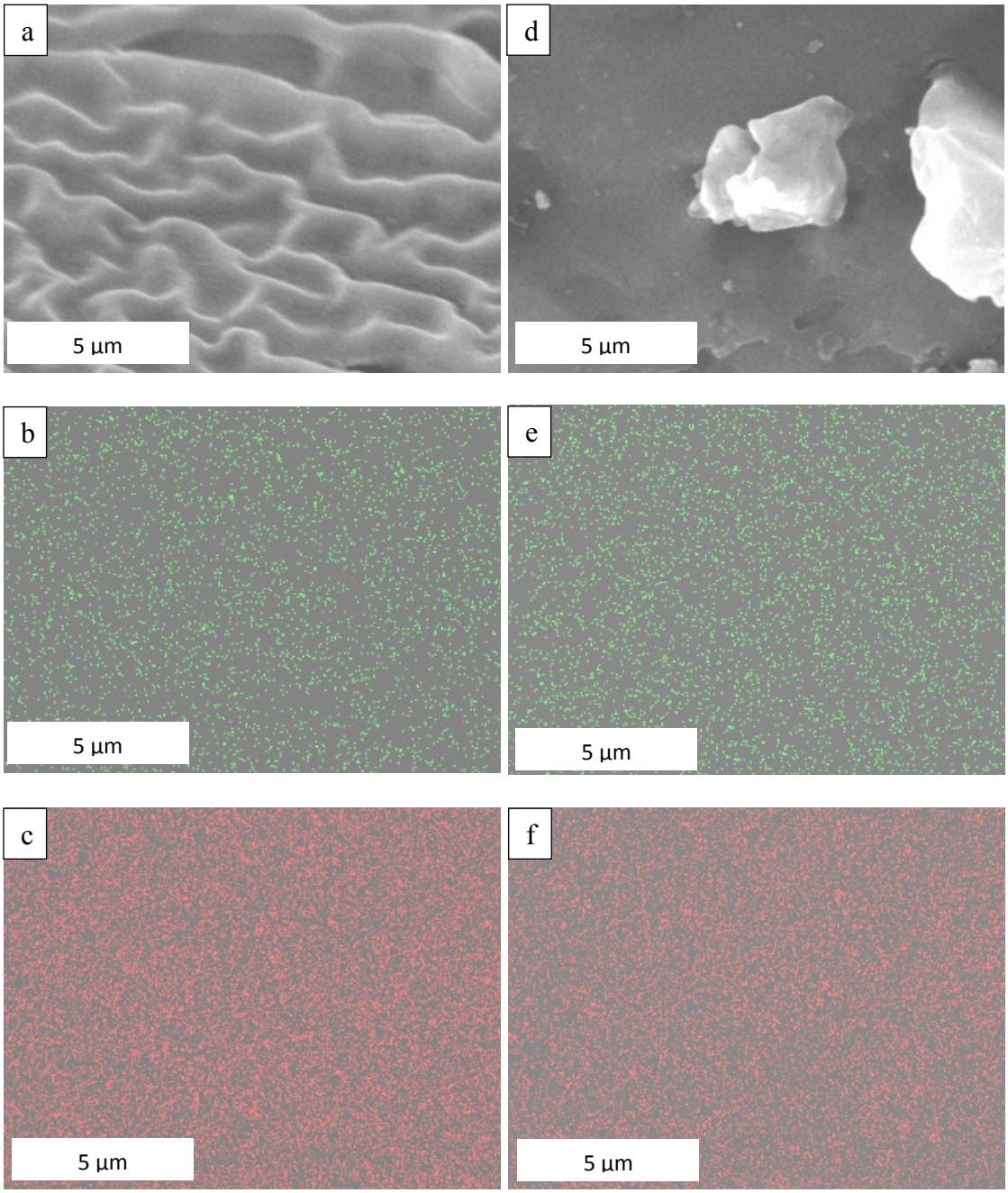

Figure S3: (a) SEM image of sample **9A$_{800\text{-}2h}$**; (b) EDX mapping of Fe; (c) EDX mapping of Ru. (d) SEM image of sample **9B$_{800\text{-}2h}$**; (e) EDX mapping of Fe; (f) EDX mapping of Ru.

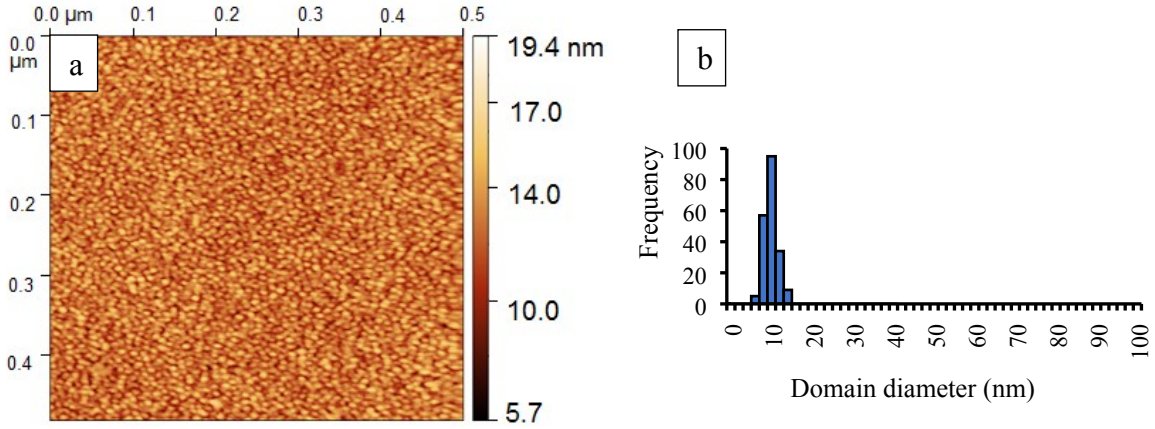

Figure S4: AFM image of thin film prepared by spin coating of 2 wt% of **9A** solution in toluene, followed by annealing at 120 ^{o}C for 24 h and plasma etching for 30 s; (b) diameter distribution histogram of 200 domains in (a).

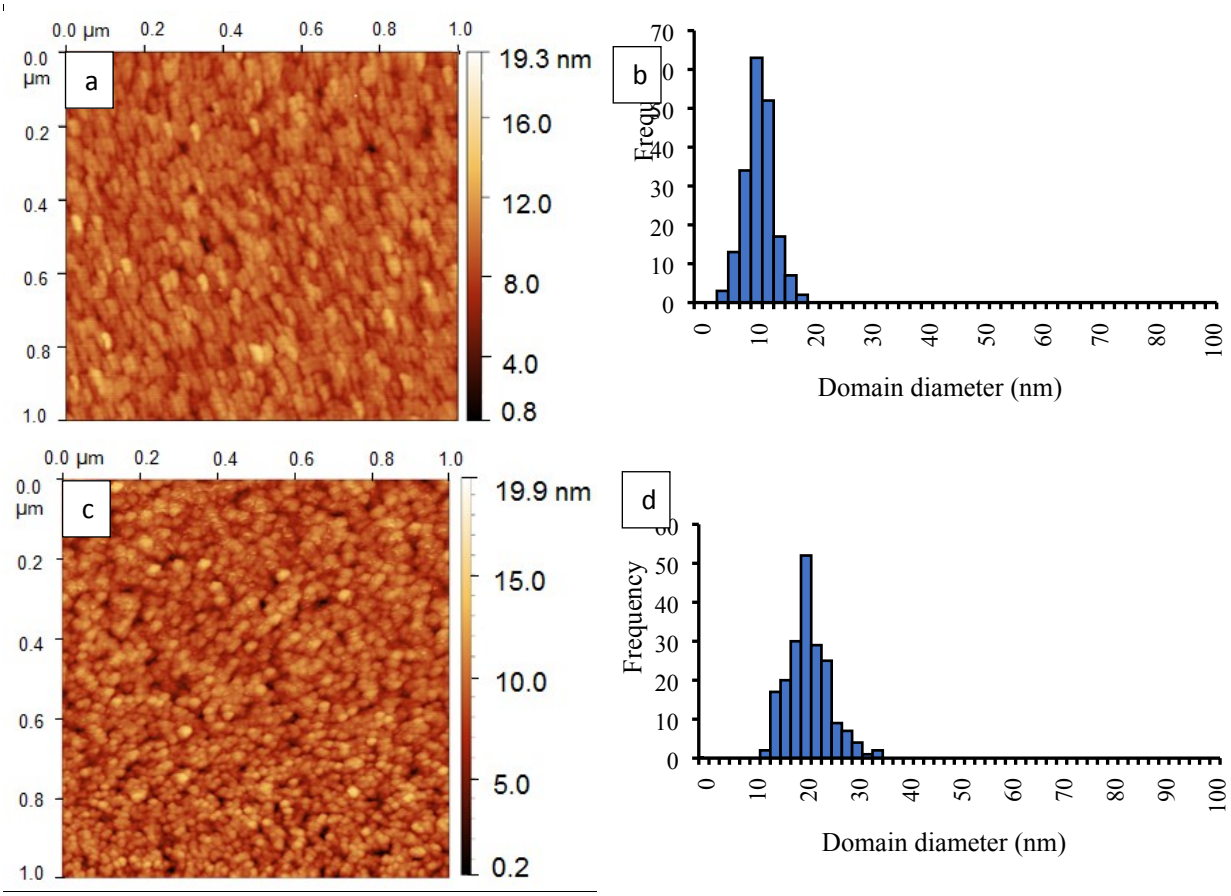

Figure S5: (a,c) AFM images of thin film prepared by spin coating a 2 wt% **9A** solution in toluene, and annealed thermally at 120 ^{o}C for 24 h prior to pyrolysis for 2 h at (a) 500 ^{o}C, (c) 800 ^{o}C; (b) diameter distribution histogram for 200 domains in (a); (d) diameter distribution histogram for 200 domains in (c).